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<b>Notice of Allowability</b>	Application No.	Applicant(s)	
	10/671,116	SCHIEK, RICHARD	
	Examiner	Art Unit	
	Sun J. Lin	2825	

**-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address--**

All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. **THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS.** This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.

1. ☒ This communication is responsive to Remarks & Declaration filed on 03/29/2006.
2. ☒ The allowed claim(s) is/are 1-32.
3. ☐ Acknowledgment is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d) or (f).
  - a) ☐ All    b) ☐ Some\*    c) ☐ None    of the:
  1. ☐ Certified copies of the priority documents have been received.
  2. ☐ Certified copies of the priority documents have been received in Application No. \_\_\_\_\_.
  3. ☐ Copies of the certified copies of the priority documents have been received in this national stage application from the International Bureau (PCT Rule 17.2(a)).

\* Certified copies not received: \_\_\_\_\_.

Applicant has THREE MONTHS FROM THE "MAILING DATE" of this communication to file a reply complying with the requirements noted below. Failure to timely comply will result in ABANDONMENT of this application.  
**THIS THREE-MONTH PERIOD IS NOT EXTENDABLE.**

4. ☐ A SUBSTITUTE OATH OR DECLARATION must be submitted. Note the attached EXAMINER'S AMENDMENT or NOTICE OF INFORMAL PATENT APPLICATION (PTO-152) which gives reason(s) why the oath or declaration is deficient.
5. ☐ CORRECTED DRAWINGS ( as "replacement sheets") must be submitted.
  - (a) ☐ including changes required by the Notice of Draftsperson's Patent Drawing Review ( PTO-948) attached
    - 1) ☐ hereto or 2) ☐ to Paper No./Mail Date \_\_\_\_\_.
  - (b) ☐ including changes required by the attached Examiner's Amendment / Comment or in the Office action of Paper No./Mail Date \_\_\_\_\_.

Identifying indicia such as the application number (see 37 CFR 1.84(c)) should be written on the drawings in the front (not the back) of each sheet. Replacement sheet(s) should be labeled as such in the header according to 37 CFR 1.121(d).
6. ☐ DEPOSIT OF and/or INFORMATION about the deposit of BIOLOGICAL MATERIAL must be submitted. Note the attached Examiner's comment regarding REQUIREMENT FOR THE DEPOSIT OF BIOLOGICAL MATERIAL.

**Attachment(s)**

- |   |  |
|---|--|
| <ol style="list-style-type: none"> <li>1. <input type="checkbox"/> Notice of References Cited (PTO-892)</li> <li>2. <input type="checkbox"/> Notice of Draftsperson's Patent Drawing Review (PTO-948)</li> <li>3. <input type="checkbox"/> Information Disclosure Statements (PTO-1449 or PTO/SB/08),<br/>Paper No./Mail Date _____</li> <li>4. <input type="checkbox"/> Examiner's Comment Regarding Requirement for Deposit<br/>of Biological Material</li> </ol> | <ol style="list-style-type: none"> <li>5. <input type="checkbox"/> Notice of Informal Patent Application (PTO-152)</li> <li>6. <input type="checkbox"/> Interview Summary (PTO-413),<br/>Paper No./Mail Date _____</li> <li>7. <input type="checkbox"/> Examiner's Amendment/Comment</li> <li>8. <input checked="" type="checkbox"/> Examiner's Statement of Reasons for Allowance</li> <li>9. <input type="checkbox"/> Other _____</li> </ol> |
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### ***Reasons for Allowance***

Applicant's submitted "*Declaration*" filed on 03/29/2006 is sufficient to overcome the examiner's cited reference ("*A New Topology Driven Method for Automatic Mask Generation from Three-Dimensional Models*") under 37 CFR 1.132.

Therefore, Claims 1 – 32 are allowed over the prior art of record. An examiner's statement of reasons for allowance is given in the following.

As to Claims 1 – 32, the prior art does not teach or fairly suggest the following subject matters:

- A method of generating two-dimensional masks from a three-dimensional model comprising reducing a three-dimensional model to a topological description of unique cross sections, and reconciling candidate masks selected from the uniqueness cross section and a cross section topology to produce two-dimensional process masks in combination with other limitations as recited in independent **Claim 1**;
- A method of generating two-dimensional masks from a three-dimensional model comprising processing individual of one or more independent bodies, which are disassembled from the three-dimensional model, comprising generating a topology tree composed of one or more nodes, categorizing the one or more nodes of the topology tree and locating deposition boundaries to define one or more deposition domains in combination with other limitations as recited in independent **Claim 9** and **Claim 18**, respectively;
- An article of manufacture, which comprises a controller and a computer readable program for generating two-dimensional masks from a three-dimensional model, the article of manufacture comprising a code capable of causing the controller to reduce a three-dimensional model to a topological description of unique cross sections, and a code capable of causing the controller to reconcile candidate masks selected from the uniqueness cross section and a cross section topology to produce two-dimensional process masks in combination with other limitations as recited in independent **Claim 22**;
- An article of manufacture, which comprises a controller and a computer readable program for generating two-dimensional masks from a three-

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dimensional model, the article of manufacture comprising a code capable of causing the controller to process individual of one or more independent bodies, which are disassembled from the three-dimensional model, comprising a code of causing a controller to generate a topology tree composed of one or more nodes, a code of causing a controller to categorize the one or more nodes of the topology tree and a code of causing a controller to locate deposition boundaries to define one or more deposition domains in combination with other limitations as recited in independent **Claim 27** and **Claim 30**, respectively;

- An apparatus for generating two-dimensional masks from a three-dimensional model comprising means for reducing a three-dimensional model to a topological description of unique cross sections, and means for reconciling candidate masks selected from the uniqueness cross section and a cross section topology to produce two-dimensional process masks in combination with other limitations as recited in independent **Claim 32**.

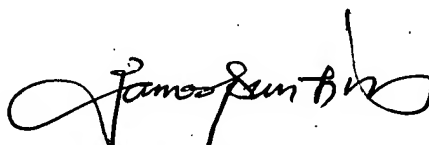
Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance".

### Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Sun J. Lin whose telephone number is (571) 272 – 1899. The examiner can normally be reached on Monday to Friday from 9:30am to 6:30pm.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is (703) 308-1782.

Sun J. Lin  
Primary Examiner  
Art Unit 2825  
April 06, 2006



SUN JAMES LIN  
PRIMARY EXAMINER